

# PHOTOMER® 2001

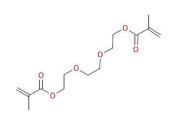
# **Methacrylated Monomer, Reactive Diluent**

## **Product Data Sheet**

#### **General Information**

PHOTOMER® 2001 is a di functional methacrylate monomer with good flexibility and chemical resistance.

#### **Chemical Data**



**Chemical Name** : Triethylene glycol dimethacrylate

 Molecular weight
 : 286.32 g/mol

 CAS No.
 : 109-16-0

 EINECS No.
 : 203-652-6

## **Specification**

Appearance Visual Clean clear liquid

Viscosity @ 25 °C Brookfield, ISO 2555 5 - 10 mPa·s

Colour (APHA) ISO 6271 ≤ 80

Acid Value ISO 660 ≤ 0.5 mg KOH/g

Moisture content Karl Fischer, ISO 4317 ≤ 0.2 % Inhibitor content ≤ 300

Inhibitor content ≤ 300

Specific Gravity @ 25°C 1,060 - 1,080

Refractive index @ 25°C ISO 489 1.4500 - 1.4700

## **Application**

PHOTOMER® 2001 could be used in UV/EB curable systems such as adhesives, flexible coatings and inks, etch resists and solder masks. PHOTOMER 2001® exhibits good flexibility, good heat and chemical resistance.

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## Storage & Handling

Storage must be in a cool, shaded, well ventilated and dry area away from direct sources of heat and sunlight. Subject to appropriate storage under the usual storage and temperature conditions, our products are durable for at least 12 months.

PHOTOMER® 2001 should be handled in accordance with good industrial practice. Further information is provided in the material safety data sheet which is available on request.

#### **Regulatory Status**

TSCA (USA), EU (Europe), IECSC (China), DSL (Canada), PICCS (Philippines), AICS (Australia), NZloC (New Zealand), ECL (Korea), ENCS (Japan), Taiwan

#### **Packaging**

PHOTOMER® 2001 is available in 200 kg steel drums.

#### Disclaimer

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